



US 20090015769 A1

(19) **United States**

(12) **Patent Application Publication**
Park

(10) **Pub. No.: US 2009/0015769 A1**
(43) **Pub. Date: Jan. 15, 2009**

(54) **SUBSTRATE FOR A LIQUID CRYSTAL DISPLAY AND A FABRICATING METHOD THEREOF**

(76) Inventor: **Jong-Jin Park, Seoul (KR)**

Correspondence Address:
MCKENNA LONG & ALDRIDGE LLP
1900 K STREET, NW
WASHINGTON, DC 20006 (US)

(21) Appl. No.: **12/232,318**

(22) Filed: **Sep. 15, 2008**

Related U.S. Application Data

(62) Division of application No. 11/011,066, filed on Dec. 15, 2004.

(30) **Foreign Application Priority Data**

Dec. 23, 2003 (KR) 10-2003-0095717

Publication Classification

(51) **Int. Cl.**
G02F 1/1335 (2006.01)
B05D 5/06 (2006.01)

(52) **U.S. Cl.** **349/106; 427/162**

(57) **ABSTRACT**

A substrate for a liquid crystal display includes a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively, first, second and third color filter patterns corresponding to the first, second and third openings, respectively, a first planarization layer on the first, second and third color filter patterns and filling the fourth opening, and a second planarization layer on the first planarization layer.

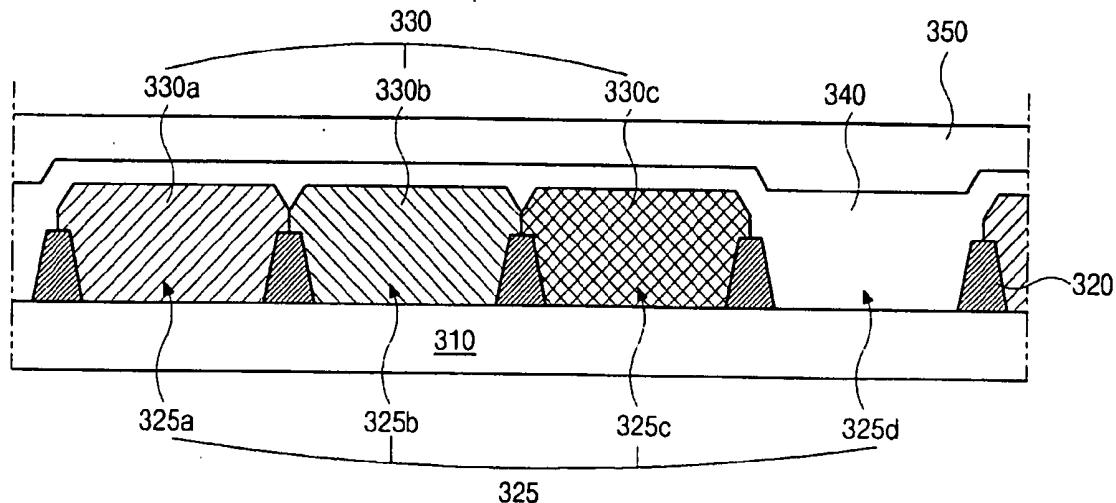


FIG. 1
RELATED ART

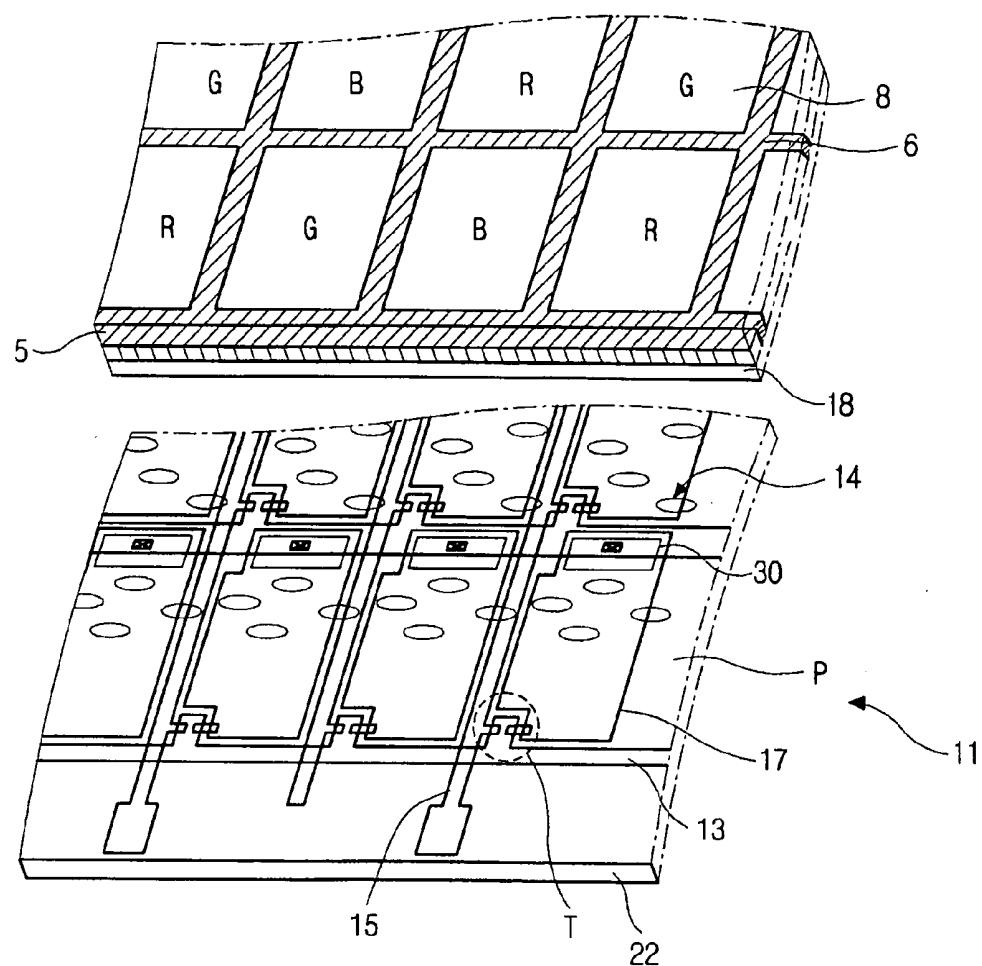


FIG. 2
RELATED ART

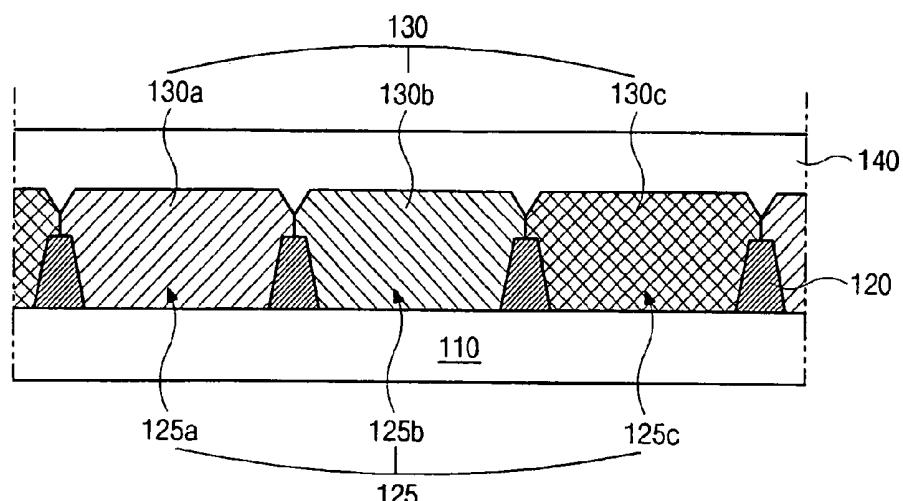


FIG. 3
RELATED ART

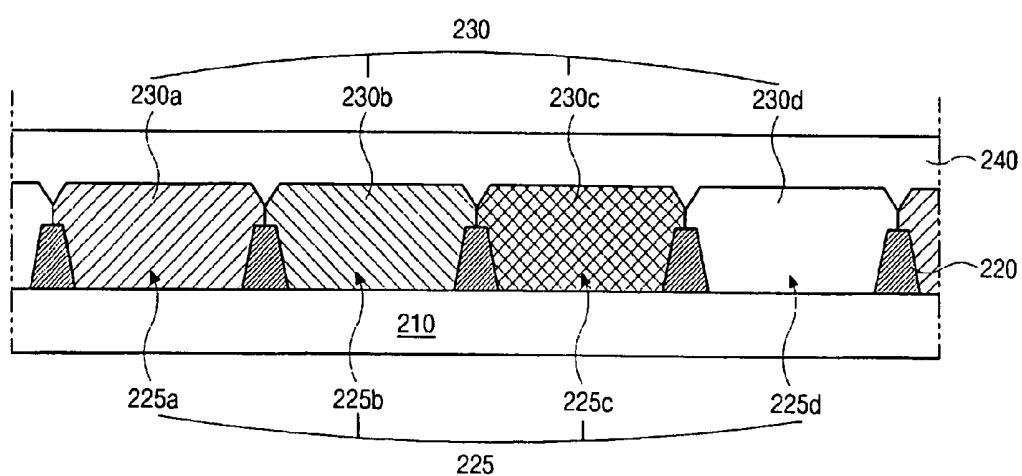


FIG. 4A
RELATED ART

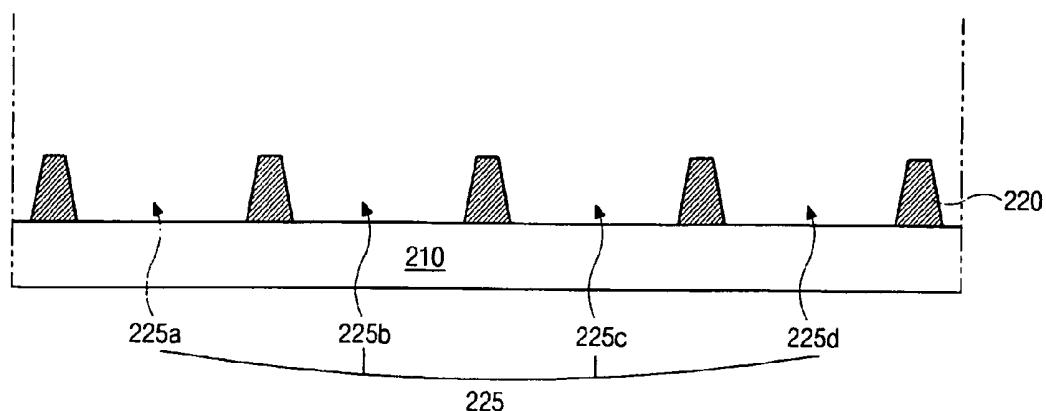


FIG. 4B
RELATED ART

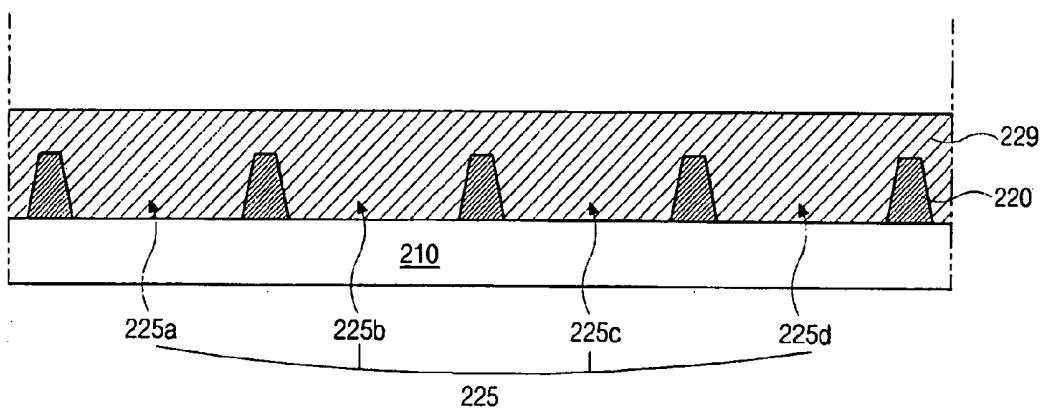


FIG. 4C
RELATED ART

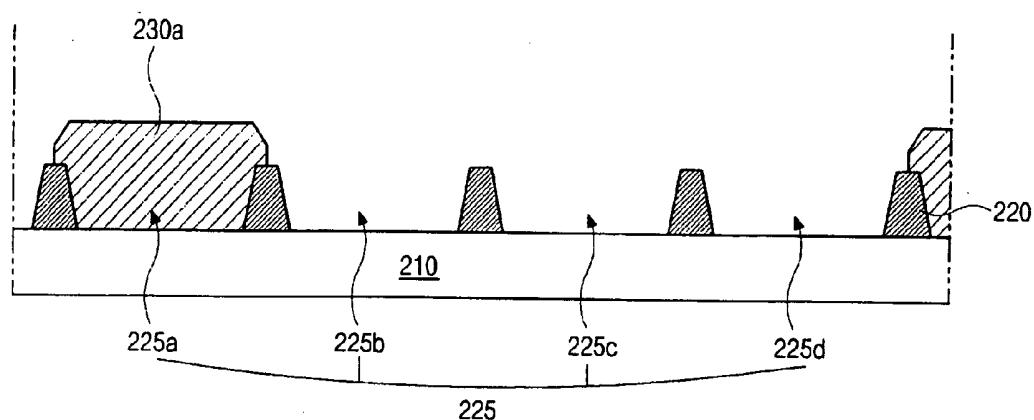


FIG. 4D
RELATED ART

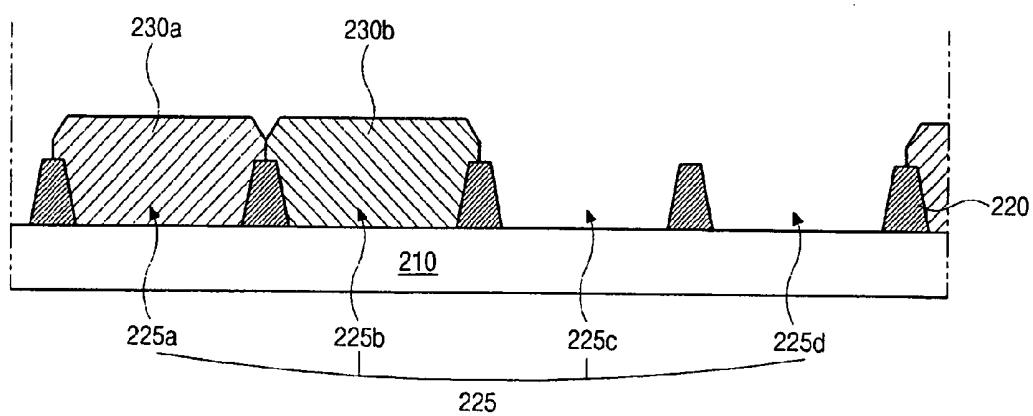


FIG. 4E
RELATED ART

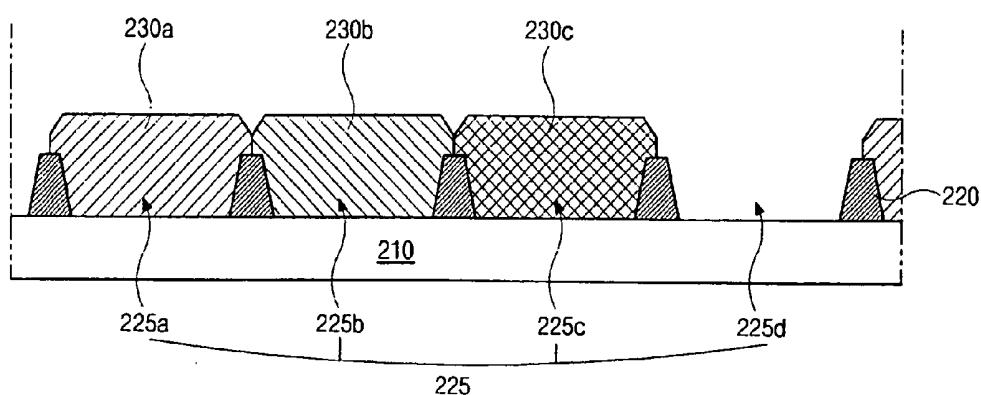


FIG. 4F
RELATED ART

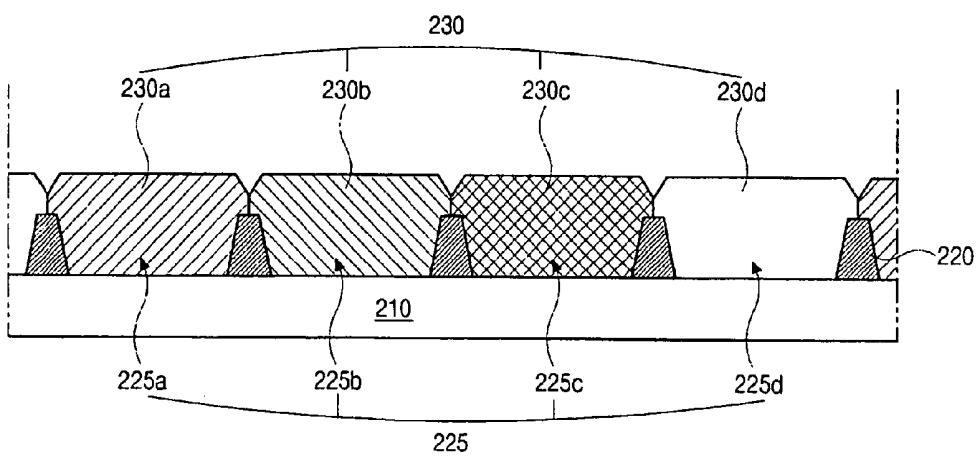


FIG. 4G
RELATED ART

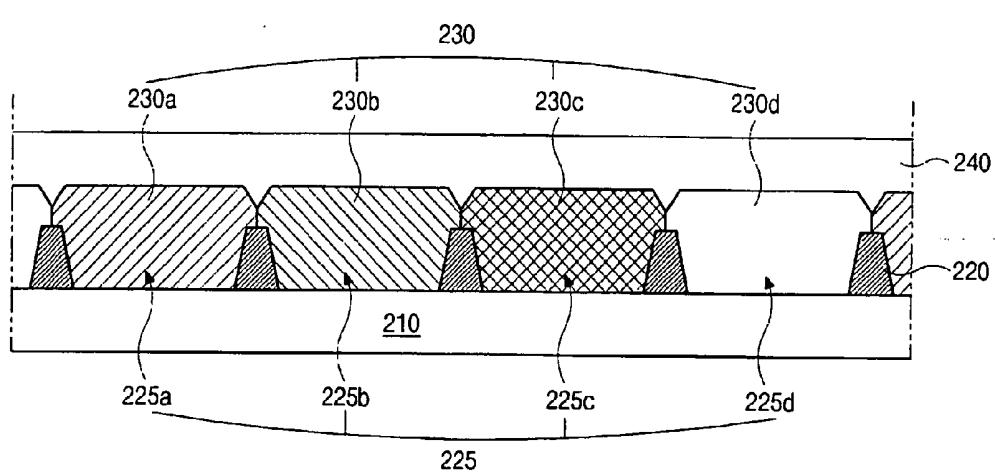


FIG. 5

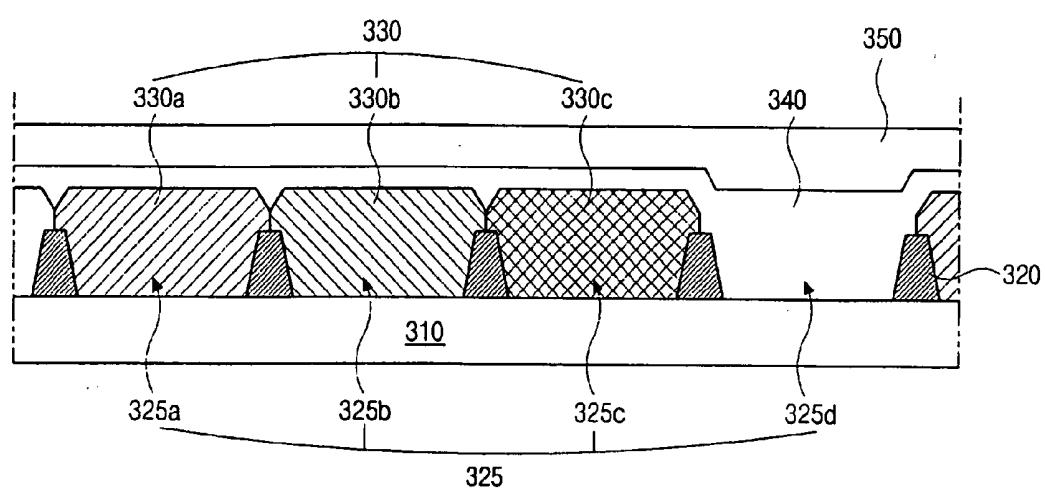


FIG. 6A

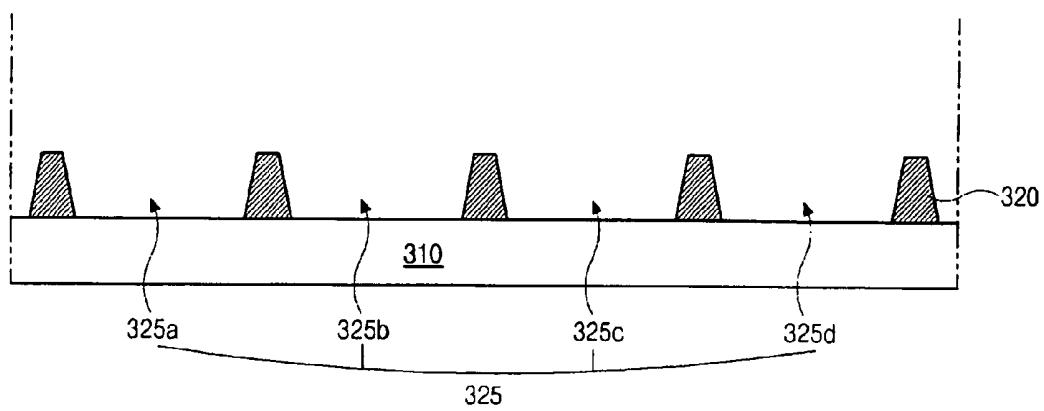


FIG. 6B

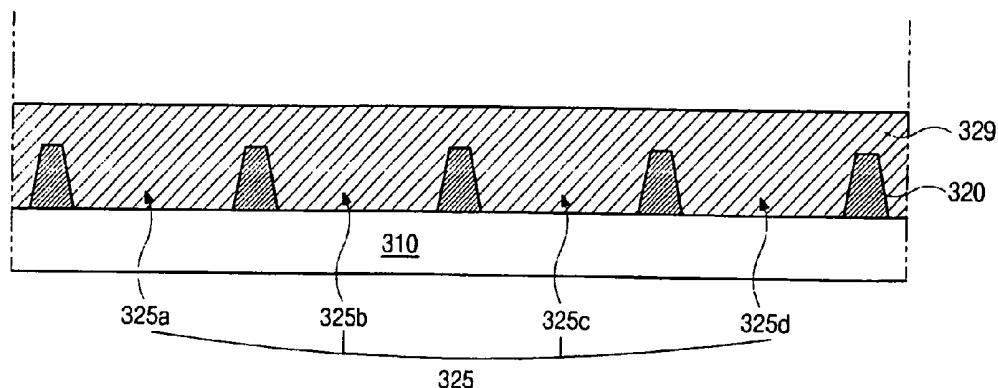


FIG. 6C

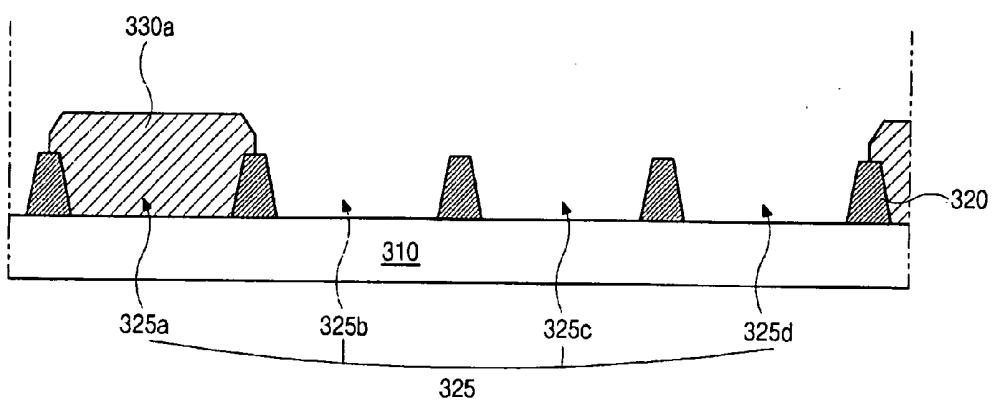


FIG. 6D

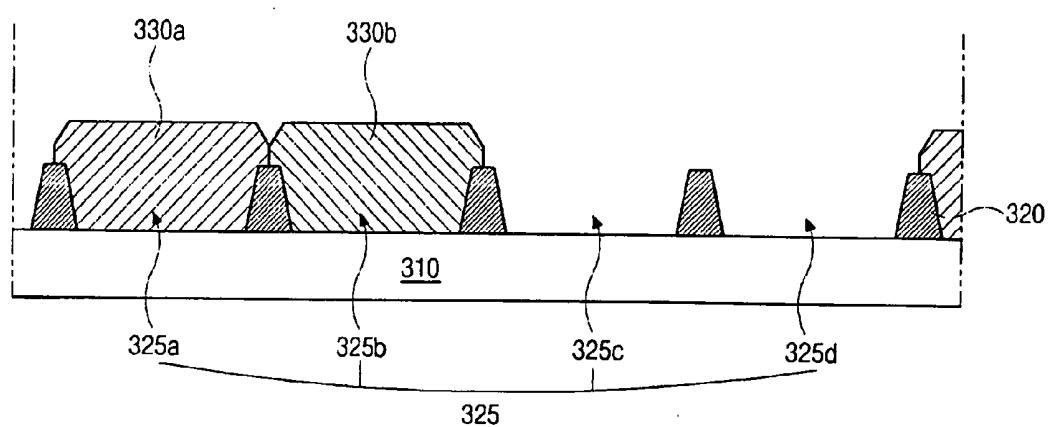


FIG. 6E

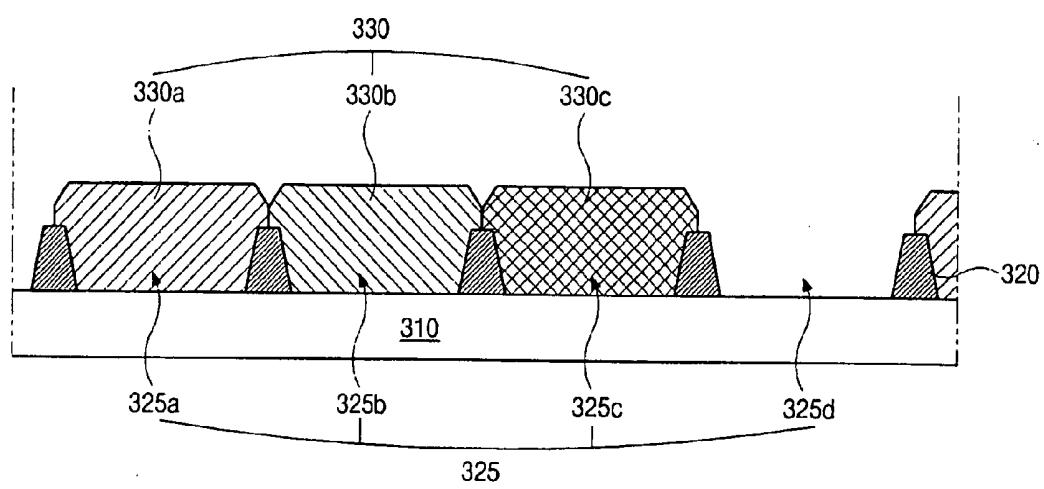


FIG. 6F

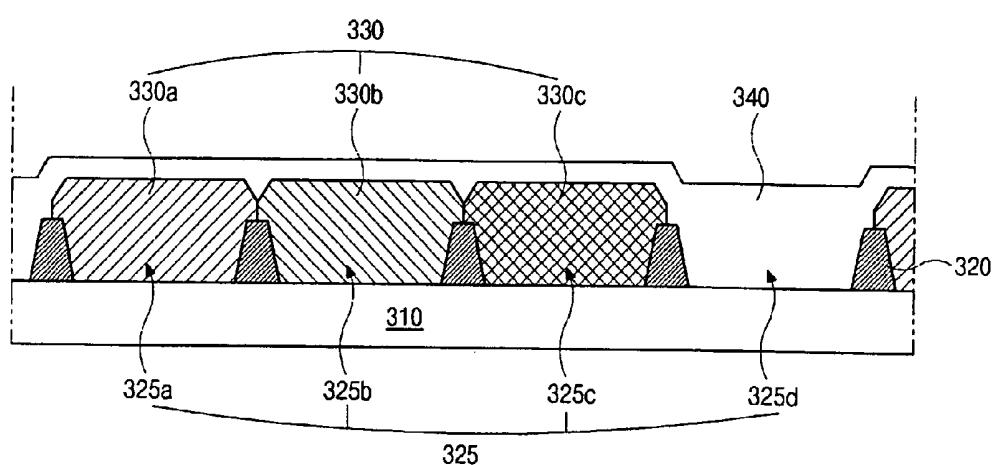


FIG. 6G

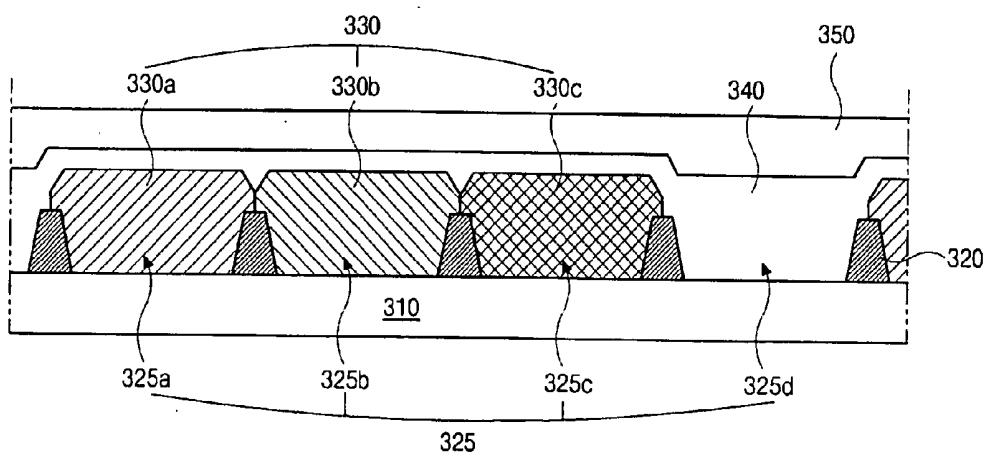


FIG. 7

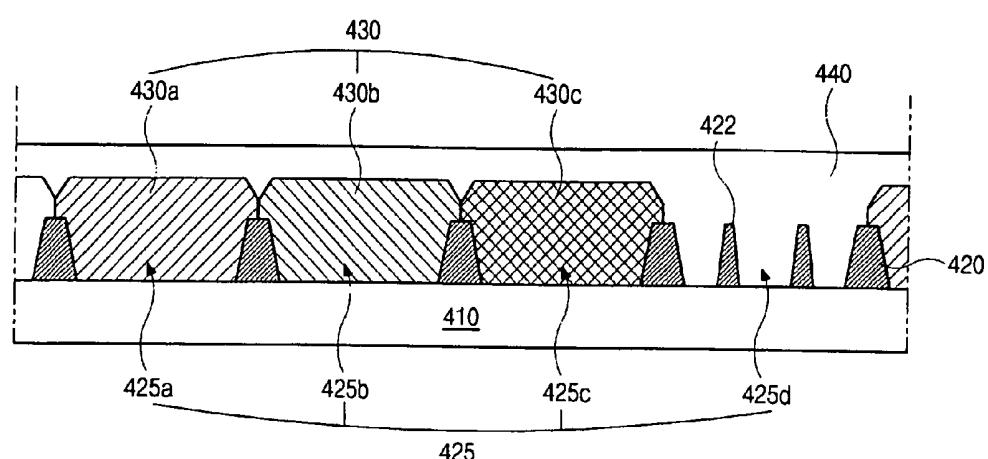


FIG. 8A

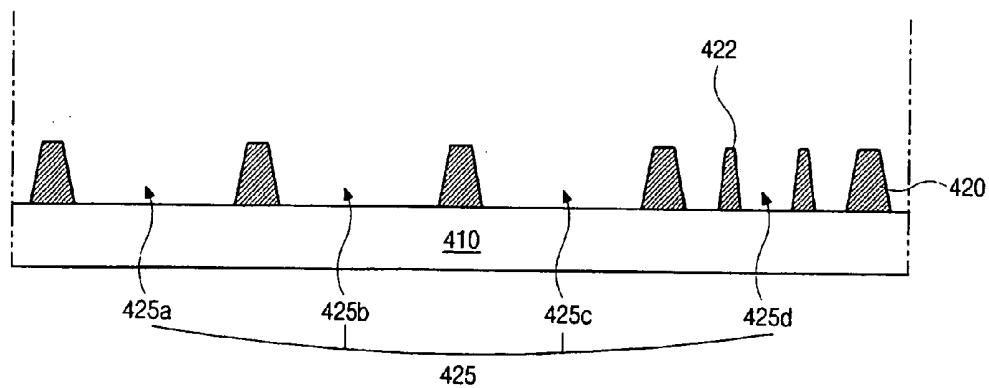


FIG. 8B

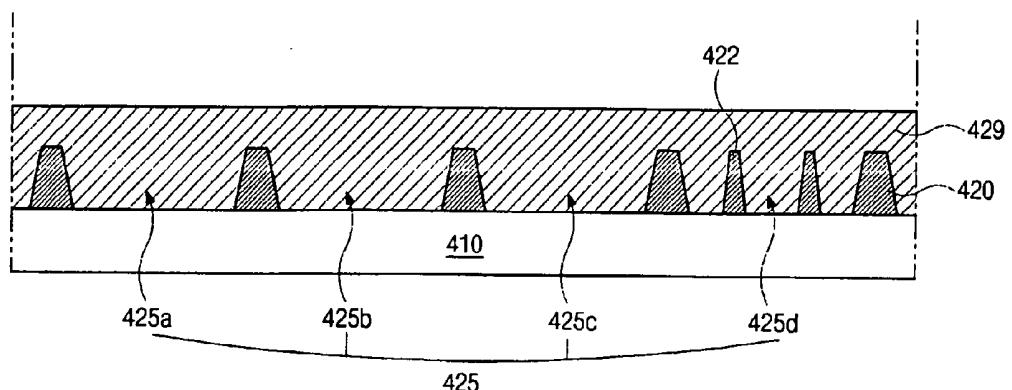


FIG. 8C

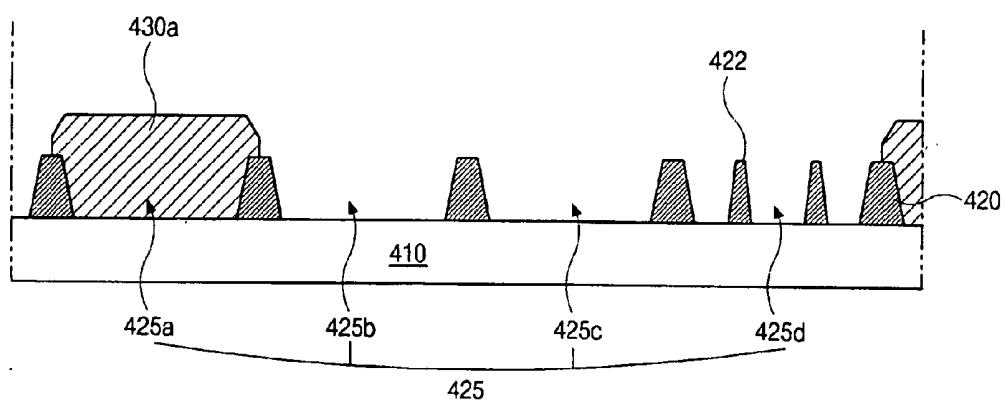


FIG. 8D

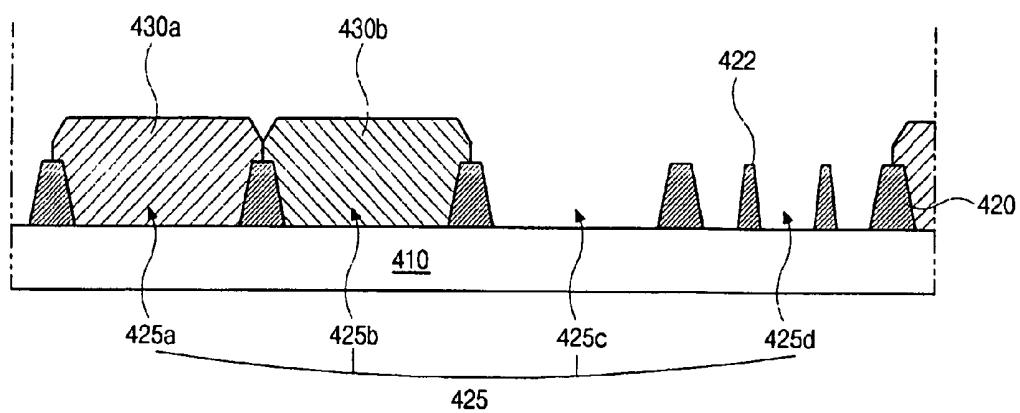


FIG. 8E

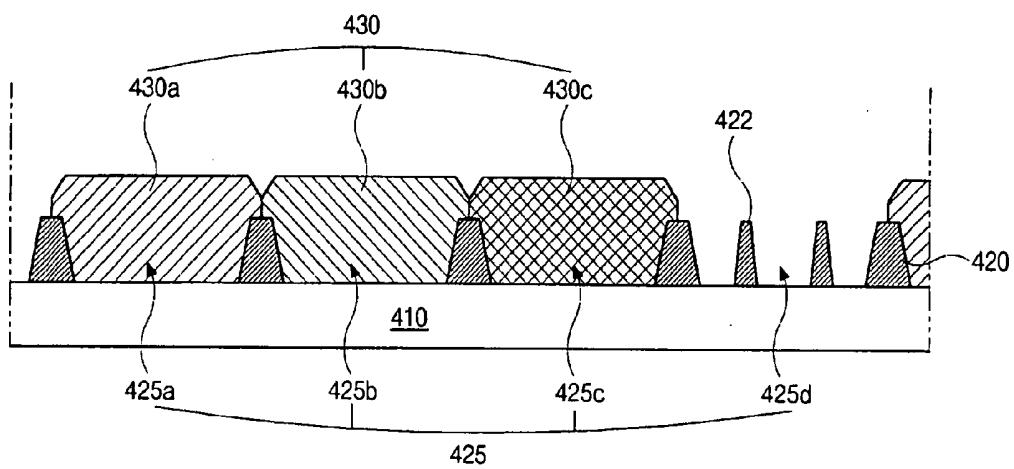
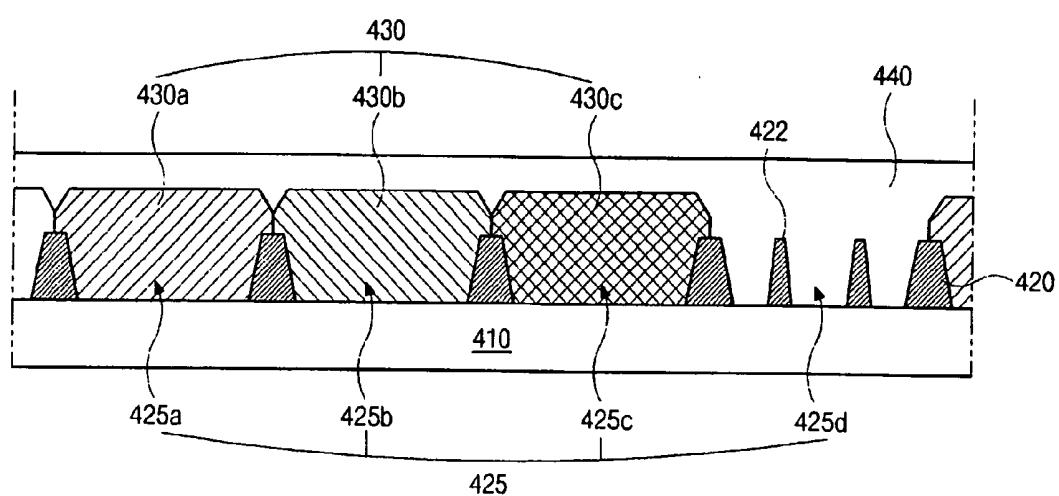


FIG. 8F



SUBSTRATE FOR A LIQUID CRYSTAL DISPLAY AND A FABRICATING METHOD THEREOF

[0001] The application claims the benefit of Korean Patent Application No. 2003-95717, filed on Dec. 23, 2003, which is hereby incorporated by reference for all purposes as if fully set forth herein.

BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The present invention relates to a liquid crystal display (LCD), and more particularly, to a color filter substrate for an LCD and a fabricating method thereof.

[0004] 2. Discussion of the Related Art

[0005] Until recently, display devices generally employed cathode-ray tubes (CRTs). Presently, many efforts are being made to study and develop various types of flat panel displays, such as liquid crystal displays (LCDs), plasma display panels (PDPs), field emission displays (FEDs), and electroluminescence displays (ELDs), as substitutions for CRTs.

[0006] Of these flat panel displays, the LCD has high resolution images, lightness, thin profile, compact size, and low voltage power supply requirements.

[0007] FIG. 1 is a schematic view of an LCD according to the related art.

[0008] In FIG. 1, an LCD 11 includes a color filter substrate 5, an array substrate 22, and a liquid crystal layer 14 interposed between the two substrates 5 and 22.

[0009] The array substrate 22 as a lower substrate includes a data line 15 and a gate line 13 to define a sub-pixel region P, a pixel electrode 17 and a thin film transistor T as a switching element in the sub-pixel region P.

[0010] The color filter substrate 5 as an upper substrate includes red, green and blue color filter patterns 8 (R, G and B) corresponding to the respective sub-pixel regions P to display red, green and blue colors, respectively, a black matrix 6 between the adjacent color filter patterns 8, and a common electrode 18 on the color filter pattern 8 and the black matrix 6.

[0011] In the LCD of FIG. 1, red, green and blue sub-pixels, which have red, green and blue color filter patterns R, G and B, respectively, constitute one pixel to display color images.

[0012] FIG. 2 is a cross-sectional view of an RGB color filter substrate for an LCD according to the related art.

[0013] In FIG. 2, an RGB color filter substrate includes red, green and blue color filter patterns 130a, 130b and 130c, and further includes a black matrix 120 having first, second and third opening 125a, 125b and 125c corresponding to the red, green and blue color filter patterns 130a, 130b and 130c. A planarization layer 140 is disposed on the color filter pattern 130 to planarize the RGB color filter substrate.

[0014] Recently, to increase brightness of displayed images, the color filter substrate includes a white color filter pattern as well as red, green and blue color filter patterns.

[0015] FIG. 3 is a cross-sectional view of an RGBW color filter substrate for an LCD according to the related art.

[0016] In FIG. 3, the RGBW color filter substrate includes red, green and blue color filter patterns 230a, 230b and 230c like the RGB color filter substrate of FIG. 2, and further includes a white color filter pattern 230d.

[0017] FIGS. 4A to 4G are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the related art.

[0018] In FIG. 4A, a light-shielding material is deposited on a substrate 210 and patterned to form a black matrix 220. The black matrix 220 includes first, second, third and fourth openings 225a, 225b, 225c and 225d corresponding to respective sub-pixel regions.

[0019] In FIG. 4B, a red color resin 229 is deposited on the substrate 210 having the black matrix 220.

[0020] In FIG. 4C, the red color resin 229 (in FIG. 4B) is patterned to form a red color filter pattern 230a in the first opening 225a.

[0021] In FIG. 4D, a green color resin is deposited on the substrate 210 having the red color filter pattern 230a and patterned to form a green color filter pattern 230b in the second opening 225b. In other words, the green color filter pattern 230b is formed in a similar method of forming the red color filter pattern 230a.

[0022] In FIGS. 4E and 4F, blue and white color filter patterns 230c and 230d are formed in the third and fourth openings 225c and 225d in a similar method of forming the red and green color filter patterns 230a and 230b.

[0023] In FIG. 4G, a planarization layer 240 is formed on the color filter pattern 230.

[0024] In the fabricating method of the related art RGBW color filter substrate, since the RGBW color filter substrate includes the white color filter pattern, in addition to patterning processes to form red, green and blue color filter patterns, a patterning process is needed to form the white color filter pattern. Therefore, processes and costs to fabricate the color filter substrate increase.

SUMMARY OF THE INVENTION

[0025] Accordingly, the present invention is directed to a substrate for a liquid crystal display and a fabricating method thereof that substantially obviates one or more of the problems due to limitations and disadvantages of the related art.

[0026] An advantage of the present invention is to provide a substrate for a liquid crystal display and a fabricating method thereof that can reduce fabrication processes and costs.

[0027] Additional features and advantages of the present invention will be set forth in the description which follows, and in part will be apparent from the description, or may be learned by practice of the invention. These and other advantages of the invention will be realized and attained by the structure particularly pointed out in the written description and claims hereof as well as the appended drawings.

[0028] To achieve these and other advantages and in accordance with the purpose of the present invention, as embodied and broadly described, a substrate for a liquid crystal display includes a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively, first, second and third color filter patterns corresponding to the first, second and third openings, respectively, a first planarization layer on the first, second and third color filter patterns and filling the fourth opening, and a second planarization layer on the first planarization layer.

[0029] In another aspect of the present invention, a substrate for a liquid crystal display (LCD) includes a black matrix on a substrate having first, second, third and fourth

sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively, at least one dummy pattern in the fourth opening, first, second and third color filter patterns corresponding to the first, second and third openings, respectively, and a planarization layer on the first, second and third color filter patterns and filling the fourth opening.

[0030] In yet another aspect of the present invention, a fabricating method of a substrate for a liquid crystal display (LCD) includes forming a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively, forming first, second and third color filter patterns corresponding to the first, second and third openings, respectively, forming a first planarization layer on the first, second and third color filter patterns, the first planarization layer filling the fourth opening, and forming a second planarization layer on the first planarization layer.

[0031] In still another aspect of the present invention, a fabricating method of a substrate for a liquid crystal display (LCD) includes forming a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively, forming at least one dummy pattern in the fourth opening, forming first, second and third color filter patterns corresponding to the first, second and third openings, respectively, and forming a planarization layer on the first, second and third color filter patterns, the planarization layer filling the fourth opening.

[0032] It is to be understood that both the foregoing general description and the following detailed description are exemplary and explanatory and are intended to provide further explanation of the invention as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0033] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this specification, illustrate embodiments of the invention and together with the description serve to explain the principles of the invention. In the drawings:

[0034] FIG. 1 is a schematic view of an LCD according to the related art;

[0035] FIG. 2 is a cross-sectional view of an RGB color filter substrate for an LCD according to the related art;

[0036] FIG. 3 is a cross-sectional view of an RGBW color filter substrate for an LCD according to the related art;

[0037] FIGS. 4A to 4G are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the related art;

[0038] FIG. 5 is a cross-sectional view of an RGBW color filter substrate for a liquid crystal display (LCD) according to a first embodiment of the present invention;

[0039] FIGS. 6A to 6G are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the first embodiment of the present invention;

[0040] FIG. 7 is a cross-sectional view of an RGBW color filter substrate for an LCD according to a second embodiment of the present invention; and

[0041] FIGS. 8A to 8F are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the second embodiment of the present invention.

DETAILED DESCRIPTION OF THE ILLUSTRATED EMBODIMENTS

[0042] Reference will now be made in detail to embodiments of the present invention, examples of which are illustrated in the accompanying drawings.

First Embodiment

[0043] FIG. 5 is a cross-sectional view of an RGBW color filter substrate for a liquid crystal display (LCD) according to a first embodiment of the present invention.

[0044] In FIG. 5, an RGBW color filter substrate includes a black matrix 320 having a opening 325, a color filter pattern 330, and first and second planarization layers 340 and 350.

[0045] The black matrix 320 is made of light-shielding material, and corresponds to array patterns such as a thin film transistor, a data line and a gate line in an array substrate to prevent emission of an abnormal light. The opening 325 corresponds to each sub-pixel region defined by a gate line and a data line crossing each other. The opening 325 includes first, second, third and fourth openings 325a, 325b, 325c and 325d corresponding to the respective sub-pixel regions, i.e. red, green, blue and white sub-pixel regions, respectively.

[0046] The color filter pattern 330 includes red, green and blue color filter patterns 330a, 330b and 330c in the first, second and third openings 325a, 325b and 325c, respectively.

[0047] The first planarization layer 340 is disposed on the color filter pattern 330 and fills the fourth opening 325d, and the second planarization layer 350 is disposed on the first planarization layer 340. The first and second planarization layers 340 and 350 planarize the RGBW substrate. Additionally, the first and second planarization layers 340 and 350 corresponding to the fourth opening 325d acts as a white color filter pattern to display white color.

[0048] Since a separate color filter pattern is not disposed in the fourth opening 325d, a surface of the first planarization layer 340 corresponding to the fourth opening 325d may be lower than that corresponding to the color filter pattern 330, and a thickness of the first planarization layer 340 corresponding to the fourth opening 325d may be thicker than that corresponding to the color filter pattern 330. A surface of the second planarization layer 350 corresponding to the fourth opening 325d may be substantially equal to that corresponding to the color filter pattern 330, and a thickness of the second planarization layer 350 corresponding to the fourth opening 325d may be thicker than that corresponding to the color filter pattern 330. Accordingly, the first and second planarization layers 340 and 350 act as a white color filter pattern as well as a layer to planarize the RGBW color filter substrate. Since the first and second planarization layers 340 and 350 act as a white color filter pattern, the first and second planarization layers 340 and 350 may be made of transparent material such as organic material including acrylic.

[0049] FIGS. 6A to 6G are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the first embodiment of the present invention.

[0050] In FIG. 6A, a light-shielding material is deposited on a substrate 310 and patterned to form a black matrix 320. The black matrix 320 includes first, second, third and fourth

openings **325a**, **325b**, **325c** and **325d** corresponding to red, green, blue and white sub-pixel regions, respectively.

[0051] In FIG. 6B, a red color resin **329** is deposited on the substrate **310** having the black matrix **320**. The red color resin **329** is optical-sensitive material.

[0052] In FIG. 6C, the red color resin **329** (in FIG. 6B) is patterned to form a red color filter pattern **330a** in the first opening **325a**. Since the red color resin is optical-sensitive material, a photo-resist needs not in photolithography to pattern the red color resin. In the patterning process for the red color pattern **330a**, a red color resin is exposed on a light with a photo-mask having a light-transmission portion and a light-blocking portion. When the red color resin is a positive-type resin, a light-exposed portion of which is removed, the light-blocking portion of the photo-mask corresponds to the first opening **325a**. On the contrary, when the red color resin is a negative-type resin, a light-exposed portion of which remains, the light-transmission portion of the photo-mask corresponds to the first opening **325a**.

[0053] In FIG. 6D, a green color resin is deposited on the substrate **310** having the red color filter pattern **330a** and patterned to form a green color filter pattern **330b** in the second opening **325b**. In other words, the green color filter pattern **330b** is formed in a similar method of forming the red color filter pattern **330a**.

[0054] In FIG. 6E, blue color filter pattern **330c** is formed in the third opening **325c** in a similar method of forming the red and green color filter patterns **330a** and **330b**.

[0055] In FIG. 6F, a first planarization layer **340** is formed on the color filter pattern **330**, and fills the fourth opening **325d**. The first planarization layer **340** may be cured after deposited.

[0056] In FIG. 6G, a second planarization layer **350** is formed on the first planarization layer **340**. The second planarization layer **350** may be cured after deposited.

[0057] In the first embodiment of the present invention, instead of a white color filter pattern, first and second planarization layers are used. Accordingly, the patterning process to form a white color filter pattern can be removed. Therefore, processes and costs to fabricate the color filter substrate can be reduced.

Second Embodiment

[0058] FIG. 7 is a cross-sectional view of an RGBW color filter substrate for an LCD according to a second embodiment of the present invention.

[0059] An RGBW color filter substrate in FIG. 7 is similar to that in FIG. 5, except for structures in the fourth opening corresponding to the white sub-pixel region. In the second embodiment, explanations of the similar parts to the first embodiment will be omitted.

[0060] In FIG. 7, the RGBW color filter substrate includes a color filter pattern **430** like that in FIG. 5. However, the RGBW color filter substrate of a second embodiment includes at least one dummy pattern **422** in a fourth opening **425d**, and one planarization layer **440** instead of the two planarization layers in the first embodiment.

[0061] Since the dummy pattern **422** is disposed in the fourth opening **425d**, the fourth opening **425d** has a smaller volume than each of other openings **425a**, **425b** and **425c**. Accordingly, instead of the two planarization layers in the first embodiment, the one planarization layer **440** may planarize the RGBW color filter substrate. To fill portions of the fourth opening **425d**, the dummy pattern **422** may have a thin

and thick shape such as a column. The dummy pattern **422** may be made of the same material as a black matrix **420**. The dummy pattern **422** may have a width thinner than the black matrix **420**. Accordingly, a surface of the planarization layer **440** corresponding to the fourth opening **425d** may be substantially equal to that corresponding to the color filter pattern **430**, and a thickness of the second planarization layer **440** corresponding to the fourth opening **425d** may be thicker than that corresponding to the color filter pattern **430**.

[0062] FIGS. 8A to 8F are cross-sectional views of a fabricating method of an RGBW color filter substrate for an LCD according to the second embodiment of the present invention. A fabricating method of the second embodiment is similar to that of the first embodiment, except for structures in the fourth opening corresponding to the white sub-pixel region.

[0063] In FIG. 8A, a light-shielding material is deposited on a substrate **410** and patterned to form a black matrix **420** and at least one dummy pattern **422**. The black matrix **420** includes first, second, third and fourth openings **425a**, **425b**, **425c** and **425d** corresponding to red, green, blue and white sub-pixel regions, respectively, and the dummy pattern **422** is disposed in the fourth opening **425d**.

[0064] In FIGS. 8B to 8E, in a method similar to the first embodiment, red, green and blue color filter patterns **430a**, **430b** and **430c** are formed in the first, second and third openings **425a**, **425b** and **425c**, respectively.

[0065] In FIG. 8F, a planarization layer **440** is formed on the color filter pattern **430** to planarize the color filter pattern **430**, and fills the fourth opening **425d** having the dummy pattern **422**.

[0066] In the second embodiment of the present invention, instead of a white color filter pattern, a dummy pattern is employed in the same process of forming the black matrix, and thus one planarization layer is enough to planarize the RGBW color filter substrate. Accordingly, patterning process to form a white color filter pattern can be removed. Therefore, processes and costs to fabricate the color filter substrate can be reduced.

[0067] It will be apparent to those skilled in the art that various modifications and variations can be made in the present invention without departing from the spirit or scope of the invention. Thus, it is intended that the present invention cover the modifications and variations of this invention provided they come within the scope of the appended claims and their equivalents.

1. A substrate for a liquid crystal display (LCD), comprising:

a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively;

first, second and third color filter patterns corresponding to the first, second and third openings, respectively;

a first planarization layer on the first, second and third color filter patterns and filling the fourth opening, wherein a surface of the first planarization layer corresponding to the fourth opening is lower than a surface of the first planarization layer corresponding to the first, second and third openings; and

a second planarization layer on the first planarization layer, wherein a top surface of the second planarization layer corresponding to the fourth opening is on a level with a

top surface of the second planarization layer corresponding to the first, second and third openings.

2. (canceled)

3. (canceled)

4. The substrate according to claim **1**, wherein the first and second planarization layers are made of transparent organic material.

5. The substrate according to claim **4**, wherein the transparent organic material includes acrylic.

6-13. (canceled)

14. A fabricating method of a substrate for a liquid crystal display (LCD), comprising:

forming a black matrix on a substrate having first, second, third and fourth sub-pixel regions, wherein the black matrix includes first, second, third and fourth openings corresponding to the first, second, third and fourth sub-pixel regions, respectively;

forming first, second and third color filter patterns corresponding to the first, second and third openings, respectively;

forming a first planarization layer on the first, second and third color filter patterns, the first planarization layer filling the fourth opening, wherein a surface of the first planarization layer corresponding to the fourth opening is lower than a surface of the first planarization layer corresponding to the first second and third openings; and forming a second planarization layer on the first planarization layer, wherein a top surface of the second planarization layer corresponding to the fourth opening is on a level with a top surface of the second planarization layer corresponding to the first, second and third openings.

15. (canceled)

16. (canceled)

17. The method according to claim **14**, wherein the first and second planarization layers are made of transparent organic material.

18. The method according to claim **17**, wherein the transparent organic material includes acrylic.

19-26. (canceled)

* * * * *

专利名称(译)	用于液晶显示器的基板及其制造方法		
公开(公告)号	US20090015769A1	公开(公告)日	2009-01-15
申请号	US12/232318	申请日	2008-09-15
[标]申请(专利权)人(译)	朴钟金		
申请(专利权)人(译)	朴钟金		
当前申请(专利权)人(译)	LG DISPLAY CO. LTD.		
[标]发明人	PARK JONG JIN		
发明人	PARK, JONG-JIN		
IPC分类号	G02F1/1335 B05D5/06 G02B5/20 G02F1/133 G02F1/1333		
CPC分类号	G02F1/1333 G02F2001/133357 G02F1/133516 G02F1/133512		
优先权	1020030095717 2003-12-23 KR		
其他公开文献	US7764347		
外部链接	Espacenet USPTO		

摘要(译)

用于液晶显示器的基板包括在具有第一，第二，第三和第四子像素区域的基板上的黑矩阵，其中黑矩阵包括对应于第一，第二，第三和第四子像素的第一，第二，第三和第四开口子像素区域，分别对应于第一，第二和第三开口的第一，第二和第三滤色器图案，第一，第二和第三滤色器图案上的第一平坦化层和填充第四开口，以及第二，第二，第二和第三滤色器图案第一平坦化层上的平坦化层。

